

Application of statistical method to investigate the effects of design parameters on the performance of microring resonator channel dropping filter

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ABSTRACT

Microring resonator (MRR)-based channel dropping filters have been extensively explored because of the high quality factor, compact size, and easy integration of fabrication. In order to design an excellent MRR wavelength filter, optimization of the design parameters are essential. In this paper, the design trade-off of MRR-based channel dropping filter was statistically studied by employing the Taguchi method. Four control factors considered were width of rings and channels, radii of the microring, upper rib waveguide height, and gap size. The analysis of variance was adopted to analyze significant trends that occurred on the free spectral range (FSR) and insertion loss (IL) performance under different sets of control factor combinations. The best parametric combination of control factors was identified in order to achieve a balance performance between large FSR and low IL using Finite-Difference Time Domain (FDTD) simulation by RSoft Inc. After optimization, the value of FSR and IL obtained was 17 nm and 0.245 dB, respectively. Confirmation tests were carried out to verify the optimized parametric combinations and a new parametric combination considering both outputs were 16 nm and 0.215 dB. The optimal combinations were 6 μm ring radius with the separation gap of 50 nm and 350 nm \times 350 nm rib waveguide cross section. Copyright © 2013 John Wiley & Sons, Ltd.

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KEY WORDS: silicon photonics; microring resonator; optical wavelength filter; Taguchi method; analysis of variance (ANOVA)

1. INTRODUCTION

Rapid development in the high-index-contrast (HIC) technology has resulted in the demonstrations of various microring resonator (MRR)-based devices, including wavelength filter [1], multiplexer [2], sensors [3], and modulators [4]. MRRs have attracted extensive research due to their advantages of high-quality factor, simple structure, as well as compact size.

Microring resonators were first proposed as integrated optical wavelength filters by Marcanti in 1969 [5]. By utilizing the HIC characteristics of silicon dioxide, a very wide free spectral range (FSR) can be realized with the possibility for the creation of very densely photonic integrated circuits systems. MRRs are ideal devices for developing almost every fundamental block in wavelength division multiplexed (WDM) networks. MRR-based wavelength filters or channel dropping filters are recently applied to filter out the required channel from a WDM signal. MRR channel dropping filter offers high wavelength selectivity, low propagation loss, and extremely small footprints [6]. A major challenge in implementing such high efficiency MRR channel dropping filter is to ensure large

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bandwidth or FSR, low loss, box-like filter response, and high out-of-band signal rejection is attained. As it is well-known, in WDM systems, it is important to have a very wide FSR so that it is capable to accommodate a huge number of information and users. Our work attempted to design a large FSR filter with an acceptable low loss. The largest FSR value of MRR filter reported so far is 32 nm at 1.55 μm telecommunication wavelengths, fabricated on silicon-on-insulator (SOI) platform [6], having the ring radius of 2.5 μm . However, the loss produced was large (4.5 dB/mm). The results show that there is a trade-off between large FSR and low propagation loss. Hence, a study to analyze the balance between both characteristics is crucial. In real applications, the overall device performance relies upon many parameters and it is difficult to determine which parameter has the most significant effect on the device performance. Therefore, many efforts were undertaken toward the optimization of design parameters to ensure the reliability of WDM systems.

To solve this, a systematic approach introduced by Genichi Taguchi based on orthogonal array (OA) experiments was applied. The Taguchi method tremendously reduces the number of experiments to be conducted and the impact of varying multiple controllable parameters to the device performance can be thoroughly investigated. This will aid researchers to achieve the best combination of design parameters or control factors to ensure an optimum quality of the MRR-based filter [7, 8]. Optimization of design parameters is the key step in the device modeling because it tremendously reduces the total manufacturing cost mainly because of fabrication, as well as research and development.

In this paper, we present results from numerical simulations which was used to characterize key optical design parameters of a laterally coupled SOI-based MRR channel dropping filter using FullWAVE software by RSoft Inc. FullWAVE is a simulation engine that ideal for the design of complex photonic devices. The simulation allows analysis of devices, such as photonic bandgaps and MRRs, that cannot be modeled with techniques as the efficient beam propagation method.

The FSR and IL of channel dropping filters are very much dependent on the ring radii, the separation gap between the input/output waveguide and ring waveguide, as well as the waveguide cross-section. In order to obtain an improved wavelength filtering, we perform the optimization of these parameters using the Taguchi method. To the best of the authors' knowledge, this study is the first of its kind to profoundly analyze the effect of control and noise factor in the modeling of a SOI-based MRR channel dropping filter prior to actual fabrication.

2. DEVICE DESCRIPTION AND THEORY

The MRR channel dropping filter can be realized by a simple topology composed of double straight waveguides coupled to a single microring as depicted schematically in Figure 1. R is the ring radius,

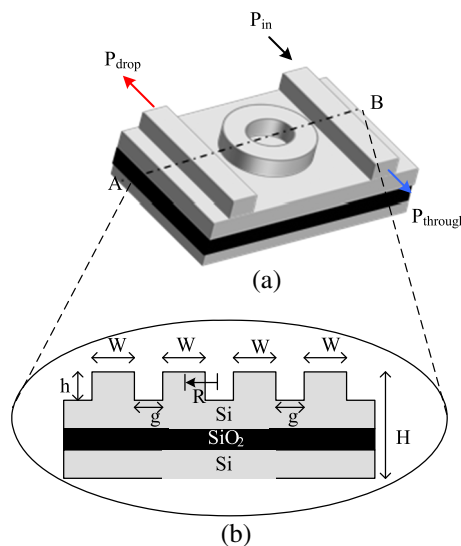


Figure 1. Layout and cross section of the proposed wavelength filter.

g is the separation gap between straight and ring waveguide, W is the waveguide width, and h is the upper rib height. These four parameters are the studied control factors in this paper. The straight waveguides or bus waveguides serve as input and output channels for the evanescent waves.

The rib dimensions are chosen in order to obtain a single mode behavior. The slab waveguide has a dimension of $0.7 \mu\text{m}$ on top of a buried oxide layer. SOI platform has been selected because of its high-index contrast, low cost, and compatibility with available facility [9, 10]. The resonance behavior can be explained by Figure 2, where it shows the on-resonance and off-resonance states for the first order of SOI MRR filter. At off-resonance state, input signal bypasses the ring and is emitted at the through port (Figure 2 (a)); whereas at the on-resonance state, light is coupled to the ring and is directed to the through port, depending on the resonance frequency (Figure 2 (b)).

An example of the simulated transmission response observed at the drop port is depicted in Figure 3. Theoretically, power transmission outputs at the through port, P_{through} , and the drop port, P_{drop} for the first-order filter can be predicted by [11]

$$P_{\text{through}} = \frac{(\lambda - \lambda_o)^2 + \left(\frac{FSR}{4\pi}\right)^2 (\kappa_p^2)^2}{(\lambda - \lambda_o)^2 + \left(\frac{FSR}{4\pi}\right)^2 (2\kappa^2 + \kappa_p^2)^2} \quad (1)$$

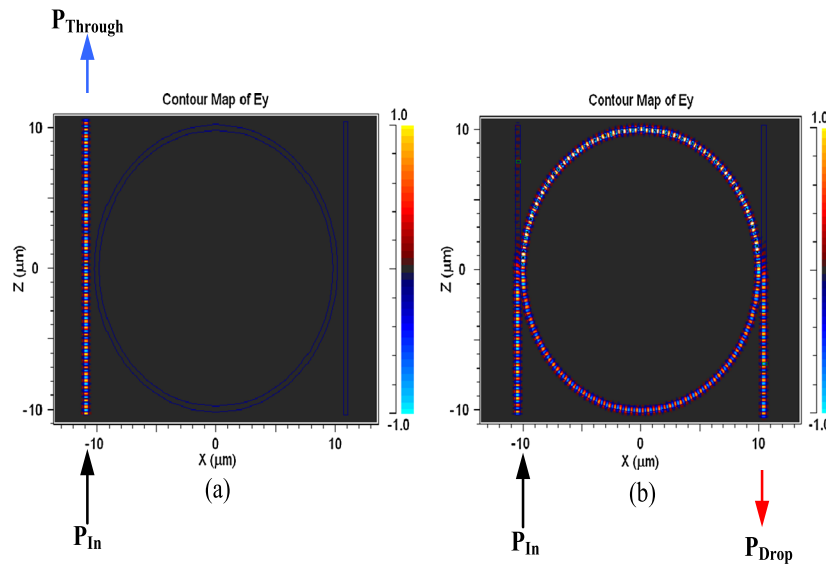


Figure 2. Resonant condition of microring resonators filter.

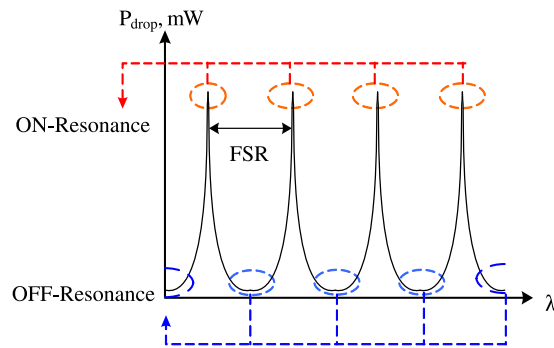


Figure 3. Transmission Response of microring resonator channel dropping filter.

$$P_{drop} = \frac{4x\left(\frac{FSR}{4\pi}\right)^2(\kappa^4)}{(\lambda - \lambda_0)^2 + \left(\frac{FSR}{4\pi}\right)^2(2\kappa^2 + \kappa_p^2)^2} \quad (2)$$

where λ_0 is the resonant wavelength, κ^2 is the power coupling coefficient between the bus waveguide and the resonator, and κ_p^2 is the propagation power loss coefficient per round trip in the MRR.

To characterize the device, TE-light was launched into the input port and the response at the output port was scanned from optical wavelengths of 1540–1570 nm. From the output power observed, the IL and FSR were calculated. Low IL is demanded in WDM network to scale down the number of amplifiers employed and hence, reduce the overall network system cost. IL is the ratio between the power received and the input power in dB, whereas the FSR can be calculated by observing two consecutive peaks as shown in Figure 3, or using equation [2] as follows:

$$FSR \approx \frac{\lambda_0^2}{n_g(\lambda)L_{eff}} \quad (3)$$

where n_g is the group refractive index and L_{eff} is the effective length.

3. TAGUCHI METHOD

In this study, we apply the Taguchi method based on OA to study the variation effect of four design parameters (R, g, W, h) on FSR and IL. OA is the matrix of numbers arranged in columns and rows. The steps involved are summarized as shown in Figure 4.

The Taguchi quality characteristics studied in this research was signal-to-noise ratio (SNR) of ‘larger the better’ for the FSR and SNR of ‘smaller the better’ for IL because we aim to produce a device that can accommodate huge bandwidth (FSR) with a satisfactory low loss.

The SNR was computed to predict the effect of each design parameters on the targeted performance and the higher value of S/N is requisite. For ‘larger the better’, the SNR, η can be calculated by

$$\eta = -10 \log_{10} \frac{1}{n} \sum_{i=1}^n \left(\frac{1}{y_i^2} \right) \quad (4)$$

where n is the number of test and y_i is the simulation value of FSR. Whereas for ‘smaller the better’, SNR, η can be calculated by

$$\eta = -10 \log_{10} \frac{1}{n} \sum_{i=1}^n (Y_1^2 + Y_1^2 \dots Y_n^2) \quad (5)$$

where Y_1 to Y_n is the value of the insertion loss.

An L_9 (3^4) array, SNR (S/N) and analysis of variance were employed for the optimization and analysis of the FSR and IL. A total of four design parameters or control factors denoted as A (Rib radius, R), B (separation gap, g), C (rib height, h), and D (waveguide width, W) were selected as shown in Table 1. Theoretically, by reducing the ring radius, FSR will be enhanced. Because of fabrication tolerances, we selected the ring radii in the ranges of 6–12 μm . Varying the separation gap between the ring and bus waveguides will not affect the FSR but the output power drops as the gap distance is increased. Even though narrow gaps enable a device with low IL to be produced, they are difficult to fabricate in actual. In addition, variation in the rib height and the waveguide width will alter the mode condition of the device. Precise control must be devoted during fabrication process to sustain the single mode condition of such waveguide. However, it is impossible for us to control all the parameters as the fabrication process relies on many parameters. Therefore, we propose a method to pre-configure the device performance by studying the effect of varying each control factor prior to

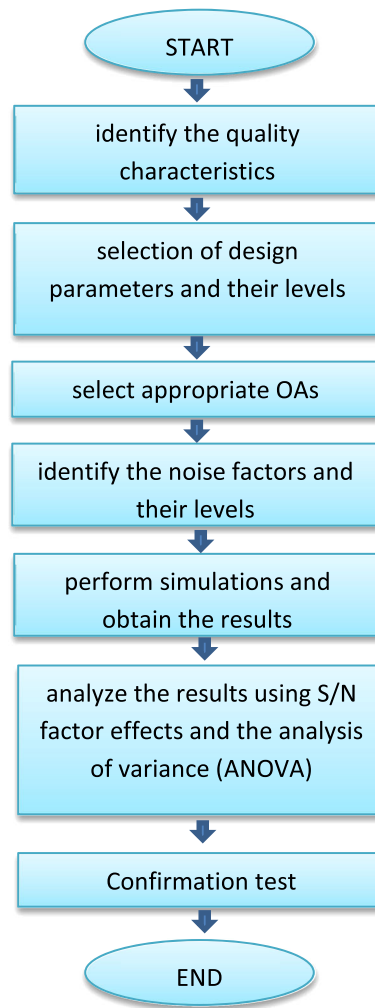


Figure 4. Process flow of the design factors optimization.

Table I. Control factors and their levels.

Symbol	Control factors	Unit	Level 1	Level 2	Level 3
A (or R)	Ring radius	μm	6	8	10
B (or g)	Separation gap	nm	30	50	70
C (or h)	Rib height	nm	300	350	400
D (or W)	Waveguide width	nm	400	375	350

the actual fabrication. The Taguchi method is suggested in this study, where the optimum combinations of selected parametric design parameters can be obtained.

The Taguchi L_9 OA performed in this study is shown in Table 2. Noise factors or uncontrollable design parameters have been selected in the analysis with three levels each (refer Table 3). They are denoted as R (surface roughness) and S (slope angle). Typically, the roughness of silicon surface generated after the lithography process is around 3 nm. Therefore, we selected the surface roughness in the range of 0–4 nm. The edge of rib waveguide structure tends to collapse during fabrication process. Hence, we also investigate the effect of sidewall angle to the device performance. The slope angle is measured from the vertical axis and from simulations, 10° is the maximum slope angle before the waveguide structure was totally damaged.

Table II. Experimental layout using orthogonal array.

Exp. no.	Control factor level			
	A	B	C	D
1	1	1	1	1
2	1	2	2	2
3	1	3	3	3
4	2	1	2	3
5	2	2	3	1
6	2	3	1	2
7	3	1	3	2
8	3	2	1	3
9	3	3	2	1

Table III. Noise factors.

Symbol	Parameter	Unit	Level 1	Level 2	Level 3
R	Surface roughness	nm	0	2	4
S	Slope angle	°	0	5	10

The device was designed to operate for TE mode of polarized light. The parameters employed in the simulations were summarized in Table 4. Here, alpha is the default imaginary index for waveguide segments.

4. RESULTS AND DISCUSSIONS

Tables 5 and 6 present the results of the FSR and IL for each experiment. It can be clearly seen from Table 5 that the combination of parameters in experiment 1 gives the highest FSR of 17 nm. Moreover, it is noticeable that the noise factors have almost no significant effect on the FSR. From Table 6, the worst parameter combination is from experiment 7 where the signal loss is more than 80%, whereas the lowest IL of ~0.5 dB was obtained from combination of factors in experiment 8. The lowest IL was produced by the combination of noise factors of R3S2.

4.2. Signal to noise (S/N) ratio and ANOVA results

Table 7 indicates the SNR value for both the FSR and IL, whereas Table 8 summarizes the mean SNR values for each control factor. Basically, the larger the SNR value, the better the output performance. From both tables, the following conclusions can be drawn. Control factor A1 which is the ring radii of 6 μm , has the most significant effect on the FSR, whereas the control factor of B2 (separation gap of 50 nm), produces the lowest insertion loss.

Figure 5 illustrates the response graph of S/N ratio for each control factors. It can be deduced that to obtain the best FSR value, the optimum combination of control factors and its level is A1, B3, C1, and D2 and for best IL value, the combination should be A1, B2, C1, and D3.

Table IV. Simulation parameters

Parameter	Value
Si refractive index	3.5
SiO ₂ refractive index	1.45
Air refractive index	1.0
Grid size	0.05
Alpha	0
Launch field type	Slab mode

Table V. Results for L_9 experiments for free spectral range values of microring resonator channel dropping filter.

Exp. no.	FSR, nm								
	R_1S_1	R_1S_2	R_1S_3	R_2S_1	R_2S_2	R_2S_3	R_3S_1	R_3S_2	R_3S_3
1	17.0	17.0	17.0	17.0	17.0	17.0	17.0	17.0	17.0
2	16.0	16.0	16.5	16.5	16.5	16.5	16.5	16.5	16.5
3	15.0	15.0	15.0	15.0	15.0	15.0	15.0	15.0	15.0
4	12.0	12.0	12.0	12.0	12.0	12.0	12.0	12.0	12.0
5	13.0	13.0	13.0	13.0	13.0	13.0	13.0	13.0	13.0
6	15.0	15.0	15.0	15.0	15.0	15.0	15.0	15.0	15.0
7	10.0	10.0	10.0	10.0	10.0	10.0	10.0	10.0	10.0
8	10.0	10.0	10.0	10.0	10.0	10.0	10.0	10.0	10.0
9	10.0	10.0	10.0	10.0	10.0	10.0	10.0	10.0	10.0

FSR, free spectral range.

Table VI. Results of L_9 experiment for insertion loss values of microring resonator channel dropping filter.

Exp. no.	Insertion loss, dB								
	R_1S_1	R_1S_2	R_1S_3	R_2S_1	R_2S_2	R_2S_3	R_3S_1	R_3S_2	R_3S_3
1	0.943	0.950	0.957	0.941	0.910	0.946	0.925	0.917	0.915
2	0.596	0.607	0.621	0.614	0.609	0.617	0.619	0.605	0.616
3	1.250	1.342	1.287	1.238	1.279	1.223	1.248	1.217	1.345
4	1.379	1.386	1.388	1.387	1.380	1.383	1.383	1.388	1.393
5	0.854	0.837	0.730	0.725	0.744	0.736	0.742	0.726	0.743
6	0.767	0.773	0.773	0.761	0.763	0.772	0.769	0.762	0.769
7	7.640	7.601	7.645	7.618	7.625	7.595	7.670	7.608	7.646
8	0.563	0.554	0.553	0.558	0.549	0.572	0.553	0.546	0.562
9	2.112	2.151	1.930	1.995	2.039	1.850	2.162	1.881	2.009

Table VII. Signal-to-noise ratio for microring resonator channel dropping wavelength filter.

Exp. no.	SNR (dB)	
	FSR	IL
1	-155.39	0.59
2	-155.71	4.27
3	-156.48	-2.08
4	-158.42	-2.83
5	-157.72	2.37
6	-156.48	2.30
7	-160.00	-17.65
8	-160.00	5.09
9	-160.00	-6.09

SNR, signal-to-noise ratio; FSR, free spectral range.

Table VIII. Signal-to-noise ratio evaluation for various microring resonator channel dropping filter performance.

Control factor	FSR			IL		
	Level 1	Level 2	Level 3	Level 1	Level 2	Level 3
A	-155.86	-157.54	-160.00	0.93	0.61	-6.22
B	-157.94	-157.81	-157.65	-6.63	3.91	-1.96
C	-157.29	-158.04	-158.07	2.66	-1.55	-5.79
D	-157.70	-157.40	-158.30	-1.04	-3.69	0.06

FSR, free spectral range; IL, insertion loss.

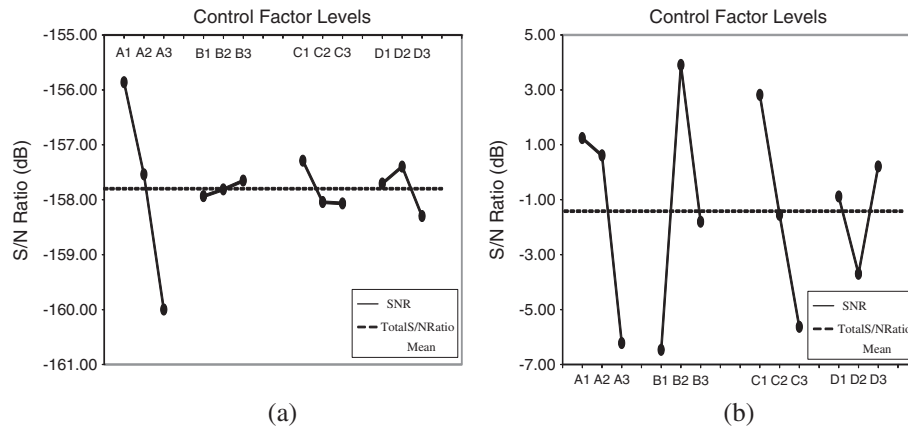


Figure 5. S/N ratio for (a) free spectral range (b) insertion loss.

From the parameters shown in Table 9, we can finally predict the parametric combination to obtain the optimum design trade-off. By comparing the percentage of control factor effects on the device performance, we have selected the control factor combination that exhibits the highest value. The optimized combinations for both FSR and IL is A1, B2, C1, and D3 or wavelength filter with 6 μm ring radius with the separation gap of 50 nm and 350 nm \times 350 nm rib waveguide cross-section. This combination is similar to the optimized combinations for IL.

4.3. Confirmation test

The confirmation test was conducted to verify the results using the predicted control factors and the final results are shown in Table 10. It confirms that the same FSR is produced as predicted. Meanwhile, the insertion loss improves almost 14% with the new setting. The result proves that the final experiment value is correlated with the predicted result with only 1.03 dB error in FSR setting and 0.08 dB error for IL. In the meantime, to find the trade-off between both outputs, a confirmation test was once again performed with the parametric combination selected before. Thereupon, the IL value is identical and the FSR lessen. The final device with control/noise factors of A1B2C1D3R3S2 gives an FSR value of 16 nm and IL of 0.215 dB.

Table IX. Optimum parametric combination for free spectral range and insertion loss and percentage of effect.

Control factor	FSR		IL	
	Level	% Factor effect	Level	% Factor effect
A	1	91	1	26
B	3	0	2	41
C	1	4	1	27
D	3	4	3	6

FSR, free spectral range; IL, insertion loss.

Table X. Predicted and confirmation results of L_9 experiment.

Optimized Value		Level	Prediction	Confirmation
FSR		A1, B3, C1, D3	17 nm	17 nm
IL		A1, B2, C1, D3	0.245 dB	0.215 dB
Both	FSR	A1, B2, C1, D3	17 nm	16 nm
	IL	A1, B2, C1, D3	0.245 dB	0.215 dB

5. CONCLUSIONS

We have presented an analysis and optimization of wavelength filter design using the Taguchi method. From this work, it is proven that choosing the appropriate design parameters is crucial in designing an optimum MRR channel dropping filter. We found that the ring radius has the most significant effect on FSR performance, whereas the separation gap has the largest effect on the IL. It also proven that the Taguchi method can be successfully applied to predict the optimum solutions in designing an MRR channel dropping filter. The final device with control/noise factors of A1B2C1D3R3S2 gives an FSR value of 16 nm and IL of 0.215 dB. This parametric combination will be utilized in the actual fabrication process. Hence, Taguchi optimization prior to fabrication provides a methodology with reduced cost and time as well provides insight into the effect of design factors on output characteristics.

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